

LASER X



Semi-auto Eutectic Die Bonder

Product Features

- Placement accuracy of $\pm 1.5 \mu\text{m}$ (3σ)
- Ability to handle tiny chips
- Apply LD and Submount cocrystal welding

Performance Parameter

	Description	Parameter
Chip	Application	COC
	Chip size	$0.15\text{mm} \leq \text{Chip size} \leq 1.5\text{mm}$
	Substrate size	$0.15\text{mm} \leq \text{Substrate size} \leq 4\text{mm}$
Velocity	Production cycle (1 chip)	70s
Accuracy	Patch pressure	10g~100g
	XY Placement accuracy	$\pm 1.5\mu\text{m}@3\sigma$ (chip<1mm)
	Die rotation accuracy	$0.3\text{deg}@3\sigma$
Camera	Sensor resolution ratio	3072x2048
	FOV	1.8x1.2(4x lens)
Eutectic System	Maximum temperature	450°C (Minimum heating time 1.5s)
	Heating method	Pulse heating
	Heating speed/Cooling speed	$\leq 100^\circ/\text{Sec}$
	Temperature accuracy	$\pm 5^\circ$
	Shielding Gas	Nitrogen
Electrical specification	Power Supply	220VAC/50Hz
	Energy Consumption	3.5kVA
Dimensions and Weight	Air	4 ~ 6Kgf/cm ²
	Dimensions	500(L)x500(W)x800 mm(H)
	Weight	100kg

